





APPLICANT'S ART CITATION (Use several sheets if necessary)		Application <b>10/045,973</b>		OFGS File No. <b>P/2292-52</b>	
		Applicant <b>Kyoung-Ri PARK et al</b>			
		Filing Date <b>January 10, 2002</b>		Group Art Unit <b>1751</b>	

  

U.S. PATENT DOCUMENTS						
Examiner Initial	Document Number	Date MM-YYYY	Name	Class	Sub-class	Filing Date If Appropriate
	US-					
	US-					
	US-					
	US-					
	US-					
	US-					
	US-					
	US-					

  

FOREIGN PATENT DOCUMENTS							
Examiner Initial	Document Number	Date MM-YYYY	Country	Class	Sub-class	Translation	
						Yes	No
<i>KW</i>	55-078406	06-1980	Japan				X
<i>ICW</i>	06-251863	09-1994	Japan				X
<i>KW</i>	61-032376	02-1986	Japan				X
<i>KW</i>	<del>61-138701</del> 62-004750	06-1988	Japan				X
<i>KW</i>	63-138701	01-1987	Japan				X

  

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)		
<i>KW</i>		Untranslated Japanese Office Action issued against corresponding Japanese application no. 2002-136543 dated February 6, 2004
<i>ICW</i>		English translation of Abstract for Japanese Laid-open application no. 55-078406
<i>KW</i>		English translation of Abstract for Japanese Laid-open application no. 06-251863
<i>ICW</i>		English translation of Abstract for Japanese Laid-open application no. 61-032376
<i>KW</i>		English translation of Abstract for Japanese Laid-open application no. 63-138701
<i>KW</i>		English translation of Abstract for Japanese Laid-open application no. 62-004750

  

Examiner <i>YAL</i>	Date Considered <i>May 14, 2009</i>
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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.